Supplemental Information

Visible-light Photocatalytic Activity of S-doped α -Bi₂O₃

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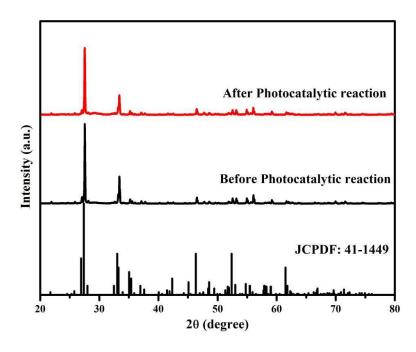


Figure S1 The XRD patterns of α-Bi₂O₃ S doped at 7 % before and after photocatalytic

reaction.

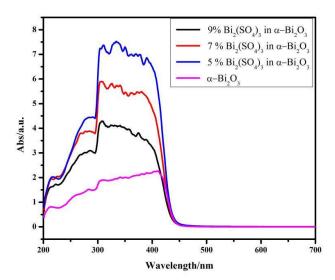


Figure S2 UV-Vis absorption spectra of compounds mixed with 5%, 7%, 9% $Bi_2(SO_4)_3$ and α - Bi_2O_3

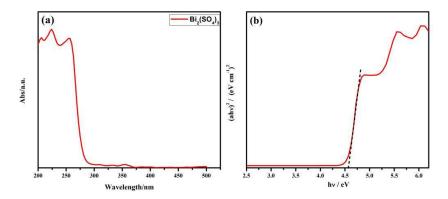


Figure S3 (a) UV-Vis absorption spectra and (b) Tauc plot of Bi₂(SO₄)₃.

The band gap of $Bi_2(SO_4)_3$ can be determined with the following Equation S1 below^{S1}.

$$\alpha h v = A(h v - E_g)^{\frac{n}{2}}$$
 (S1)

The α , ν , Eg, A, and n are the absorption coefficient, the incident light frequency, the band gap, a constant and an integer, respectively. The values of n and Eg were obtained as follows:

First, the approximate value of Eg was estimated through extrapolating the straight line to the wavelength axis (Fig. S2(a)), and then plotting $ln(\alpha hv)$ vs. ln(hv-Eg) (inset of Fig. S2(a)). Thus, the slope of the straightest line near the band edge is the value of n.

Second, plot $(\alpha h v)^{2/n}$ vs. hv, and then evaluate the band gap Eg (4.57 eV) by drawing an extension line to the hv axis intercept (Fig. S2(b)).

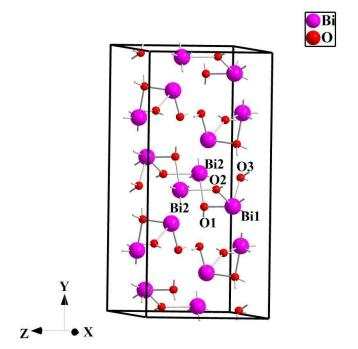


Figure S4 The crystal structure of $\alpha\text{-Bi}_2\text{O}_3$ with marked asymmetric Bi and O sites.

Refence

(S1) Butler, M. A. Photoelectrolysis and Physics Properties of the Semiconducting Electrode WO₂. *J. Appl. Phys.* **1977**, 48, 1914-1920.